



# Standard Practice for Evaluation of Automotive Polish<sup>1</sup>

This standard is issued under the fixed designation D3836; the number immediately following the designation indicates the year of original adoption or, in the case of revision, the year of last revision. A number in parentheses indicates the year of last reapproval. A superscript epsilon ( $\epsilon$ ) indicates an editorial change since the last revision or reapproval.

## 1. Scope

1.1 This practice covers testing properties and apparatus used in evaluating the performance of automotive polishes. This practice is applicable to products that are commonly referred to as car/auto wax, cleaner wax, polish, etc.

1.2 The values stated in SI units are to be regarded as standard. No other units of measurement are included in this standard.

1.3 *This standard does not purport to address all of the safety concerns, if any, associated with its use. It is the responsibility of the user of this standard to establish appropriate safety and health practices and determine the applicability of regulatory limitations prior to use.*

## 2. Referenced Documents

2.1 *ASTM Standard:*

**D1133 Test Method for Kauri-Butanol Value of Hydrocarbon Solvents**

## 3. Terminology

3.1 *Definitions of Terms Specific to This Standard:*

3.1.1 *automotive polish*—liquid or paste formulation for cleaning and improving the appearance of automobile finishes.

## 4. Significance and Use

4.1 This practice is intended to define the properties to be tested, the apparatus to use, and the comparisons of product performance. It is recognized that considerable discretion exists among formulators and marketers of automotive polish on what properties or performance characteristics are most important for their products. This practice is flexible enough to honor this fact within the confines of the automotive polish definition.

4.2 The methods of this practice are subjective and empirical in order to conform to the basic practices of the industry and to allow flexibility in testing.

<sup>1</sup> This practice is under the jurisdiction of ASTM Committee D21 on Polishes and is the direct responsibility of Subcommittee D21.04 on Performance Tests.

Current edition approved Oct. 1, 2013. Published October 2013. Originally approved in 1979. Last previous edition approved in 2007 as D3836 – 94 (2007). DOI: 10.1520/D3836-13.

## 5. Apparatus and Materials

5.1 *Test Polish.*

5.2 *Control Polish*—The control polish is selected for comparison to the test polish. It may be a competitive product, a modified formulation of the test polish, etc. It should be recognized that automotive polishes are formulated to perform different functions. This should be taken into account when interpreting results and choosing the control polish.

5.3 *Test Substrates*—The test substrate shall be one for which the test polish is intended (**Note 1**). The test surface shall be in good physical condition, not badly cracked, scratched, or otherwise damaged so as to interfere with evaluation of polish properties. The minimum test surface area for each sample shall be 1290 cm<sup>2</sup>.

**NOTE 1**—It is important to select a test substrate for which a particular polish is intended. For example, if a particular polish is intended for a certain make of car only, then the test substrate should reflect this. Standard paint panels that were previously available through ASTM have been discontinued as of January 1, 1988. It became very difficult to maintain paint panels that were representative of all current and past paint technologies used to manufacture automotive finishes. Since 5.3 requires that the test substrate be one for which the test polish is intended, it is in the best interest of the user of this practice to determine and obtain the appropriate test surface or coating, or both. ASTM Committee D21 on Polishes suggests if further assistance is needed in determining or obtaining appropriate test substrates that contact be made with automotive paint manufacturers, automobile manufacturers, or re-painting services.

5.4 *Polishing Cloth*—The same type and size of polishing cloth shall be used with each sample tested. Separate cloths shall be used for each sample. Materials such as washed cheese cloth, rumple cloth, flannel, cotton diaper cloth, and nonwoven fabrics are suitable for this purpose. Felt or paper shall not be used.

5.5 *Cleaning Solvent:*

5.5.1 Aliphatic solvents with kauri butanol (Kb) values less than 38. (See Test Method **D1133**.)

5.5.2 Water/isopropanol (70/30).

5.6 *Eye Droppers and Distilled or Deionized Water.*

5.7 *Masking Tape*, with a 9.5-mm width.

5.8 *Thermometer.*

5.9 *Humidity Gage.*

## 6. Test Conditions

6.1 The equilibrated temperature and relative humidity of the test runs shall be measured and recorded. The temperature shall be within 13 to 29°C with a relative humidity of 20 to 80 %.

6.2 The substrate shall have the same temperature as the surrounding area.

## 7. Personnel and Instructions

7.1 The application and evaluation of the test and control polishes requires four individuals. They shall be capable of making discriminating judgments of subjective physical and aesthetic properties. Training and orientation to specific product performance characteristics may be required.

7.2 The four persons each apply the polishes to one of the four test substrates. Each person will rate the ease of use and other application properties that they experienced. Each person will rate each of the four test panels for all of the pertinent performance properties being tested. This means there will be four ratings of application properties and twelve sets of ratings of other polish performance properties.

NOTE 2—For development work the observations of an individual experimenter may be substituted as long as the decrease in accuracy is considered.

## 8. Procedure

8.1 *Cleaning of Test Substrates*—Using soft cotton towels, first clean the test substrate thoroughly with an aliphatic solvent having a kauri butanol value less than 38. Wipe dry. Using new soft cotton towels, reclean with a water/isopropanol solvent mixture (70/30). Wipe dry with a clean soft cotton towel.

NOTE 3—If polishes containing resins or reactive polymers, or both, or unknown polishes have been previously used on the test substrate, preclean with an abrasive cleaner to ensure their complete removal.

8.2 *Surface Subdivision*—Divide the precleaned surface of each test substrate and outline by tape with uniform squares.

8.3 *Blind Testing*—The test polish and control polish samples will be labeled in code so that the identity and status of the samples is not known to the testers.

8.4 *Application of Polish*—Assuming the control polish or the test polish is a commercially available product, follow the manufacturer’s directions. When in doubt on the method of use, the directions for similar products may be used. Equal volumes of control and test polish shall be used to avoid excessively thin or heavy coats of polish. One or two applications may be used depending on the substrate and the discretion of the tester. The same number of coats must be used for both the test polish and the control polish.

## 9. Placement of Polishes

9.1 *Method A*—A controlled randomized method laying out the test (X) and control (C) polishes is represented as follows:

Test Panel	Left	Center	Right
1	C	X	C
2	C	C	X
3	X	C	X
4	X	X	C

These four positionings should be written on tags and drawn randomly by each of the four who apply the polishes.

9.2 *Method B*—A controlled randomized method of laying out the test (X) and control (C) polishes is represented as follows:

Test Panel	Left	Right
1	C	X
2	X	C
3	C	X
4	X	C

These four positionings should be written on tags and drawn randomly by each of the four who apply the polishes.

## 10. Evaluation

10.1 *General*—Comparison is made between the test polish and the control by reporting relative performance of left versus center versus right (Method A) or left versus right (Method B).

10.2 *Application Properties*—During the application of the polish evaluate relative performance of all or any number of the following properties:

10.2.1 *Ease of Application*—During the application of the polishes note the ease of wetting, spreadability, and absence of drag.

10.2.2 *Cleaning*—Following the application of the polishes inspect the discoloration, if any, on applicators (towels). Also note the effect of applying the polishes on the test surfaces.

10.2.3 *Drying Rate*—Take readings of time in minutes for each polish to dry.

10.2.4 *Ease of Wipe Off*—Note effort necessary to wipe off each of the polishes from test substrate.

10.2.5 *Powdering*—Note the degree of powdering, if any, during the wipe off of polishes from test substrate.

10.2.6 *Ease of Rub Up to Maximum Gloss*—During application of the polishes, note the time and ease with which each product develops maximum gloss.

10.3 *Final Properties*—Five to ten minutes following the application of the polishes, evaluate relative performance of all or any number of the following properties:

10.3.1 *Gloss*—Evaluate as depth of gloss.

10.3.2 *Uniformity*—Observe the surface for streaks, unpolished dry spots, and general uniformity.

10.3.3 *Distinctness of Image*—Observe the clearness or sharpness of an image of an object in the polished surface. Overhead lights, face, hand, or other objects may be used for reflection. This test may be eliminated for low-luster surfaces that do not possess mirror-like finishes.

10.3.4 *Smear and Mar Resistance*—Smear is the degree of oiliness or greasiness after the polish is rubbed up to the desired polish appearance. Mar is the degree of film damage resulting from a glancing blow to the polish substrate. Check smear by making a design such as an “S” with a smoothly rounded object (finger or glass or metal rod) wrapped in a soft cotton cloth. A glancing blow with knuckles or a soft object such as a book or magazine may be used for determining the degree of mar.

10.3.5 *Film Healing*—Observe the length of time required for the polish to develop resistance to smear and mar in 10.3.4.







*ASTM International takes no position respecting the validity of any patent rights asserted in connection with any item mentioned in this standard. Users of this standard are expressly advised that determination of the validity of any such patent rights, and the risk of infringement of such rights, are entirely their own responsibility.*

*This standard is subject to revision at any time by the responsible technical committee and must be reviewed every five years and if not revised, either reapproved or withdrawn. Your comments are invited either for revision of this standard or for additional standards and should be addressed to ASTM International Headquarters. Your comments will receive careful consideration at a meeting of the responsible technical committee, which you may attend. If you feel that your comments have not received a fair hearing you should make your views known to the ASTM Committee on Standards, at the address shown below.*

*This standard is copyrighted by ASTM International, 100 Barr Harbor Drive, PO Box C700, West Conshohocken, PA 19428-2959, United States. Individual reprints (single or multiple copies) of this standard may be obtained by contacting ASTM at the above address or at 610-832-9585 (phone), 610-832-9555 (fax), or [service@astm.org](mailto:service@astm.org) (e-mail); or through the ASTM website ([www.astm.org](http://www.astm.org)). Permission rights to photocopy the standard may also be secured from the ASTM website ([www.astm.org/COPYRIGHT/](http://www.astm.org/COPYRIGHT/)).*